

Docket No.: 52352-785

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of
George Jonathan KLUTH, et al.

Serial No.: 10/071,207

Group Art Unit: 2811

Filed: February 11, 2002

Examiner: GUERRERO, Maria F.

For: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE WITH
SUPERSATURATED SOURCE/DRAIN EXTENSIONS AND METAL SILICIDE
CONTACTS

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
Washington, DC 20231

Sir:

Noting the Office Action of December 31, 2002 wherein restriction has been required, Applicant(s) hereby elect Group I (claims 1-18) with traverse for prosecution in the above-identified application.

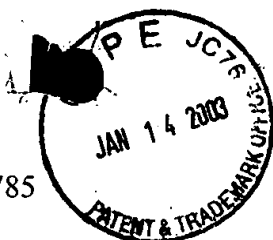
To the extent necessary, a petition for an extension of time under 37 C.F.R. 1.136 is hereby made. Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,
MCDERMOTT, WILL & EMERY

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